09/53, 163

## UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO. : 6.

: 6,740,590 B1

DATED : May 25, 2004

Page 1 of 1

INVENTOR(S) : Yano et al.

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Title page, Item [54] and Column 1, lines 1-5,

Title, should read:

-- AQUEOUS DISPERSION, AQUEOUS DISPERSION FOR CHEMICAL MECHANICAL POLISHING USED FOR MANUFACTURE OF SEMICONDUCTOR DEVICES, METHOD FOR MANUFACTURE OF SEMICONDUCTOR DEVICES, AND METHOD FOR FORMATION OF EMBEDDED WIRING --

This certificate supersedes Certificate of Correction issued February 15, 2005.

Signed and Sealed this

Nineteenth Day of April, 2005

JON W. DUDAS
Director of the United States Patent and Trademark Office